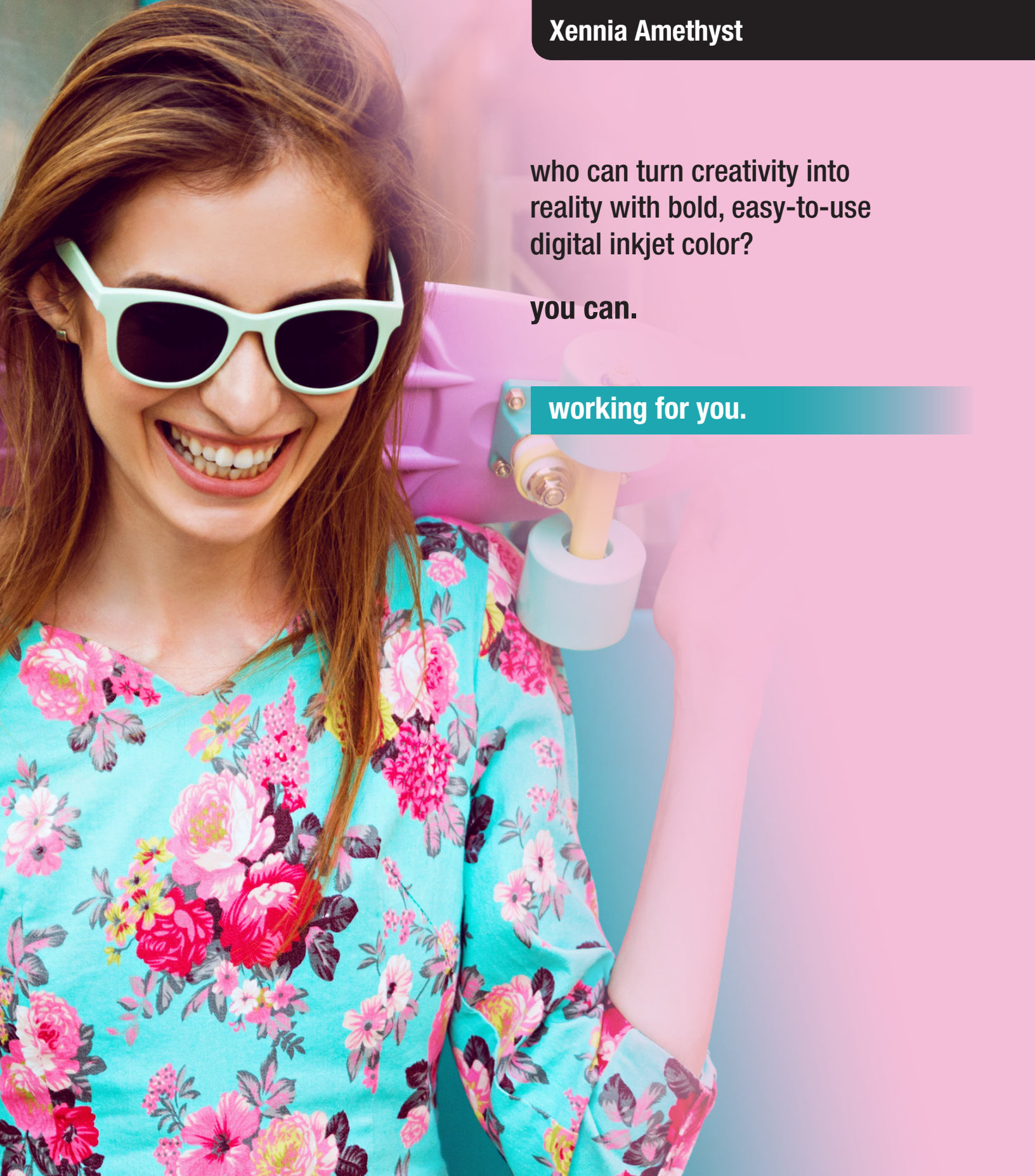


Xennia Amethyst

who can turn creativity into
reality with bold, easy-to-use
digital inkjet color?

you can.

working for you.



SunChemical[®]
a member of the DIC group 
Color & Comfort

Turn creativity into reality with bold, easy-to-use digital inkjet color

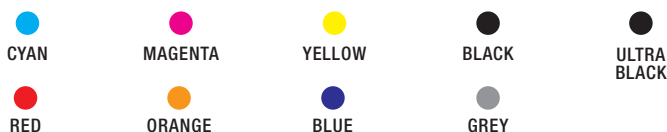
Sun Chemical's globally renowned water-based reactive dye ink, Xennia Amethyst, has the potential to truly revolutionize your digital inkjet printing. Designed for direct printing onto cotton, viscose, silk and cellulosic substrates, Xennia Amethyst provides a high color gamut coupled with outstanding printing performance.

Compatible across a range of printheads, Xennia Amethyst empowers you to achieve excellent results that will differentiate your textile products from the competition.

Key performance benefits

- Easy installation and start-up
- Excellent printhead compatibility
- Consistent color sharpness and vibrancy
- Environmentally responsible solution
- Stability over long production runs
- Minimal maintenance and increased open time
- GOTS compliant

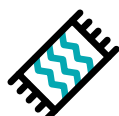
Available colors



Applications for Xennia Amethyst



Fashion apparel

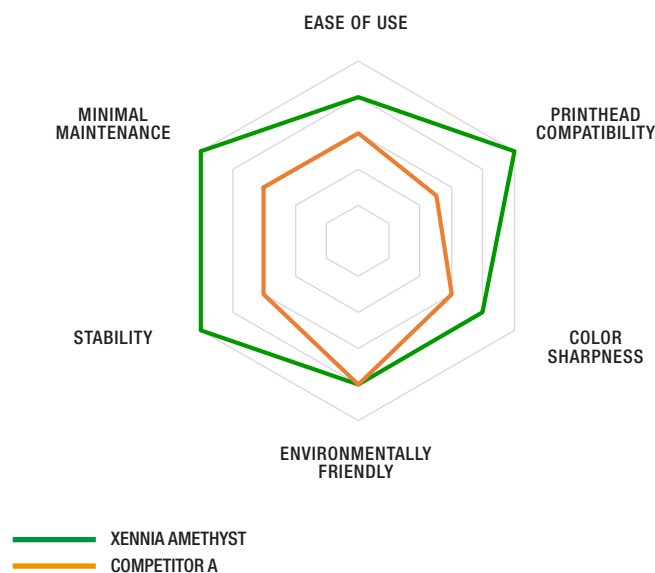


Interior Textiles

Innovation to set you apart

Xennia Amethyst is formulated only using MCT dyes to offer the best balance of color and fixation conditions combined with long lasting printhead lifetime. Xennia Amethyst Ultra Black delivers the deepest shade of black using only MCT dyes.

See it to believe it



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